PATENT

Docket No.: 034299-682

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

CANT:

Marc Rabarot et al.

CONFIRMATION NO.: Unknown

SERIAL NO .

10/567,889

FILING DATE:

February 7, 2006

TITLE:

Fabrication Method for Patterns with Inclined Flanks by Photolithography

EXAMINER:

Unassigned

ART UNIT:

Unassigned

CERTIFICATE OF MAILING

I hereby certify that this paper is being deposited with the United States Postal Service, Express Mail Label No. EV310855444US addressed to: Mail Stop Amendment, Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on the date printed below:

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INFORMATION DISCLOSURE STATEMENT

In compliance with the duty of disclosure under 37 C.F.R. §§ 1.56, 1.97 and 1.98, applicant hereby submits this Information Disclosure Statement (IDS) including a Form PTO-1449 containing a list of references which may be material to the examination of the above-referenced application. This submission is not to be construed as a representation that a prior art search has been conducted, that additional information material to the examination of this application does not exist, or that any one or more of the listed references constitutes prior art.

The Examiner is urged to carefully consider this Information Disclosure Statement and all the listed references, and to indicate same by initialing the appropriate portion(s) of the Form PTO-1449 and forwarding an initialed copy to applicant.

If this box \boxtimes is checked, this application was filed after June 30, 2003 and qualifies for the blanket waiver of deposit of copies of U.S. Patents and U.S. Patent Application Publications in accordance with the written waiver of 37 CFR §1.98 (a)(2)(i) Official Gazette Published in

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Official Gazette Notices of August 5, 2003 (1273OG55). Accordingly, such copies are not submitted.

I

This statement is filed pursuant to (CHECK ONE BOX):

37 C.F.R. § 1.97(b). This information disclosure statement is filed either: (1) within three months of the filing date of a national application other than a continued prosecution application under §1.53(d); (2) within three months of the date of entry of the national stage as set forth in 37 C.F.R. §1.491 in an international application; (3) before the mailing date of a first office action on the merits; or (4) before the mailing of a first office action after the filing of a Request for Continued Examination under 37 C.F.R. §1.114, whichever event occurs last.

Accordingly, this information disclosure statement requires no fee and no certification.

37 C.F.R. § 1.97(c).

This information disclosure statement is filed after the period specified in 37 C.F.R. § 1.97(b), but before the mailing date of any of the following:

- (1) a final action under 37 C.F.R. § 1.113;
- (2) a notice of allowance under 37 C.F.R. § 1.311; or
- (3) an action that otherwise closes prosecution in the application.

Accordingly, this information disclosure statement requires either:

- (1) the fee specified in 37 C.F.R. § 1.17(p) for submission of an information disclosure statement under 37 C.F.R. § 1.97(c); or
 - (2) a certification according to 37 C.F.R. § 1.97 (e)(1) or (2).

37 C.F.R. § 1.97(d).

This information disclosure statement is filed after the period specified in 37 C.F.R. § 1.97 (c).

Accordingly, this information disclosure statement requires:

- (1) a certification in accordance with 37 C.F.R. § 1.97(e); and
- (2) the fee specified in 37 C.F.R. § 1.17 (p) to consider an information disclosure statement under 37 C.F.R. § 1.97(d).

If this statement crosses in the mail with an office action, or is otherwise not in the indicated category of 37 C.F.R. §1.97, it is respectfully requested that this statement be treated in the next appropriate category and made of record. To the extent required, please treat this paper as a conditional petition for acceptance of the information disclosure statement.

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II

Fees Due (CHECK ONE BOX):	
\boxtimes	No fee is due.
	The fee specified in 37 C.F.R. § 1.17(p) for submission of an information disclosure statement under 37 C.F.R. § 1.97(c) or 37 C.F.R. § 1.97(d) is enclosed (\$180).
III	
Certification (CHECK ONE BOX):	
\boxtimes	No certification is necessary.
	Pursuant to 37 C.F.R. § 1.97(e)(1), the undersigned hereby certifies: That each item of information contained in this information disclosure statement was first cited in a communication from a foreign patent office in a counterpart foreign application not more than three months prior to the filing of this information disclosure statement.
	Pursuant to 37 C.F.R. § 1.97(e)(2), the undersigned hereby certifies: No item of information contained in this information disclosure statement was cited in a communication from a foreign patent office in a counterpart foreign application, and, to the knowledge of the undersigned after making reasonable inquiry, no item of information contained in this information disclosure statement was known to any individual designated in 37 C.F.R. §1.56(c) more than three months prior to the filing of this information disclosure statement.
IV	
Please	e charge any additional required fee or credit any overpayment to our deposit
account number 50-1698.	
	Respectfully submitted, THELEN REID & PRIEST LLP
Dated: May	9, 2006 Khaled Shami Reg. No. 38,745

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Page 1 of 1 MAY 1 2 2006 PROPERTY OF TRADEN Atty. Docket No. Serial No. Form PTO 1449 034299-682 10/567,889 (Rev. 2-32) U.S. Department of Commerce Patent and Trademark Office Applicant: Marc Rabarot et al. Information Disclosure Statement by Applicant Filed: Group: 2/7/2006 Unassigned (Use several sheets if necessary) U.S. Patent Documents Filing Date Document No. Date Name Class Subclass Init. 4,444,616 04/24/1984 Fujita et al. 156 628 4,912,022 Urquhart et al. 430 396 03/27/1990 5,045,439 09/03/1991 Maner et al. 430 394 **Foreign Documents** Translation Yes Class Subclass No Init. Document No. Date Country 27/14 $\overline{\mathbf{x}}$ G03B DE 1 459 719 12/31/1976 Germany B 29 C 59/16 X DE 196 52 463 06/18/1998 Germany JP 1 1327154 G03F 7/20 X 11/26/1999 Japan (Abstract) Other Documents (Including Author, Title, Date, Pertinent Pages, etc.) BEURET, C. et al., "Microfabrication of 3D Multidirectional Inclined Structures by UV Lithography and Electroplating," IEEE, January 1994, pp. 81-85. CHOI, Yoonsu et al., "Continuously-Varying, Three-Dimensional SU-8 Structures: Fabrication of Inclined Magnetic Actuators," IEEE, February 2002, pp. 176-179. FEIERTAG, Gregor et al., "Sloped Irradiation Techniques in Deep X-Ray Lithography for 3-D Shaping of Microstructures," SPIE Vol. 3048, 1997, pp. 136-145.

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Examiner: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include a copy of this form with the next communication to applicant.